

L13 ANSWER 1 OF 2 WPIX COPYRIGHT 2006 THE THOMSON CORP on STN  
AN 1986-025245 [04] WPIX  
DNN N1986-018379 DNC C1986-010680  
TI Forming fine contoured pattern on moulding - involves applying photosensitive resin between base film surface and mould surface.  
DC A32 G06 P75 P83 S06 T04  
PA (NIPQ) DAINIPPON PRINTING CO LTD  
CYC 1  
PI JP 60247590 A 19851207 (198604)\* 3 <--  
ADT JP 60247590 A JP 1984-103992 19840523  
PRAI JP 1984-103992 19840523  
IC B41J005-12; B41M003-06; C08J007-04; G03C005-00  
AB JP 60247590 A UPAB: 19930922  
A method of forming a fine contoured pattern includes treating the surface of a mould having on the surface a fine contoured pattern and also smooth surface part with a releasing treatment, applying a photosensitive resin on the surface, placing a base film on there, exposing them to light so that the resin is hardened, and removing the mould.  
1,2/2  
FS CPI EPI GMPI  
FA AB  
MC CPI: A08-M03; A11-B04B; A11-C02B; A12-B07; G06-D; G06-F03  
EPI: S06-A01X; T04-G04

L13 ANSWER 2 OF 2 JAPIO (C) 2006 JPO on STN  
AN 1985-247590 JAPIO  
TI FORMATION OF PICTURE PATTERN HAVING FINE EMBOSSED PATTERN  
IN NAGASAKI OSAMU  
PA DAINIPPON PRINTING CO LTD  
PI JP 60247590 A 19851207 Showa  
AI JP 1984-103992 (JP59103992 Showa) 19840523  
PRAI JP 1984-103992 19840523  
SO PATENT ABSTRACTS OF JAPAN (CD-ROM), Unexamined Applications, Vol. 1985  
IC ICM B41M003-06  
ICS B41J005-12; C08J007-04; G03C005-00  
AB PURPOSE: To inexpensively prepare a facing paper, by a method wherein the fine embossed pattern and smooth surface of a matrix are transferred on a cured resin and a character, a mark or a color is printed to a base film from the back surface thereof in matching relation to the transferred pattern by screen printing.  
CONSTITUTION: Releasing treatment is applied to the surface of a matrix 1 having fine embossed patterns 11A and partial smooth surfaces 12A on the surface thereof and a photosensitive resin 2A is applied to the treated surface of said matrix 1 while a base film 3 is laminated to the resin which is, in turn, exposed through said film 3 to be cured before the matrix 1 is released. After the fine embossed patterns 11A and the smooth surfaces 12A of the matrix 1 are transferred to the cured resin 2B as mentioned above, a character, a mark or a color is printed on said base film 3 from the back surface thereof in matching relation to the transferred patterns by screen printing. By this method, a facing paper provided with a picture pattern, which has the fine embossed patterns and the smooth surfaces corresponding to the matrix in combination, and having printing 4 on the back surface thereof can be formed.  
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